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International Journal For Research in  
Applied Science and Engineering Technology



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# **INTERNATIONAL JOURNAL FOR RESEARCH**

IN APPLIED SCIENCE & ENGINEERING TECHNOLOGY

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**Volume: 5      Issue: XII      Month of publication: December 2017**

**DOI:**

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# Synthesis, Characterization and Gas sensing properties of Cr surface modified BaTiO<sub>3</sub> thick films

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**Abstract:** Barium titanate BaTiO<sub>3</sub> thick films with surface modification by Cr were prepared to improve the response, recovery time and tailoring the operating temperature, when the surface modified thick films are exposed to H<sub>2</sub>S. The thick film sensor is prepared by screen printing technique. The gas sensing performances of BT films were tested to various gases by using static gas sensing system at various operating temperatures. The pure BT film showed maximum response to H<sub>2</sub>S gas at 350°C. Cr-BT films were determined at various operating temperatures ranging from 100 to 450°C to H<sub>2</sub>S gas. The very short response and recovery time are the important features of this CrBT film to NH<sub>3</sub> gas

**Keywords:** BaTiO<sub>3</sub>, Thick films, NH<sub>3</sub> gas sensor, Sensitivity, Selectivity

## I. INTRODUCTION

Barium titanate (BaTiO<sub>3</sub>) is one of the most intensively investigated ferroelectrics and has been widely used in electronic industry in applications for capacitors, thermocouples, transducers, sensors and actuators, etc. A number of studies have focused on the chemistry and physics of the response of these materials to gases. Depending on the conditions, these compounds can behave as n- or p-type semiconductors. Because of their structural similarity, similar mechanisms of interaction with gases are expected to occur for these compounds, although the relative importance of the mechanisms for any specific operating condition would depend, in each instance, on the specific compound. It is well known that a number of perovskite oxides (ABO<sub>3</sub>) have been used as gas sensor materials because of their stability in thermal and chemical atmospheres. It is capable of detecting a particular gas in the high temperature region, 175-450°C, near and above the temperature giving the maximum resistivity[1]. Modifications in the microstructure, the processing parameters and also the concentration of acceptor/donor dopants can vary the negative temperature coefficient of the resistance (NTCR) and conductivity of BaTiO<sub>3</sub>. It is also known in literature[2]-[6] that PTCR (positive temperature coefficient region) disappears completely when donor-doped BaTiO<sub>3</sub> was annealed at high temperatures in atmosphere of low oxygen partial pressure.[7] BaTiO<sub>3</sub> is well known for the detection of CO[8]-[11], CO<sub>2</sub> [10]-[12], humidity [13], etc. Various attempts have been made to improve the selectivity and sensitivity of BaTiO<sub>3</sub> by using dopants and additives [14,15]. There are a few reports dealing with BaTiO<sub>3</sub>-based gas sensors. Efforts are, therefore, made to develop BaTiO<sub>3</sub> - based gas sensors and for the improvement in its sensing performance by doping and modifying the surface of the thick films. Pure and modified BaTiO<sub>3</sub> are observed to be most sensitive to H<sub>2</sub>S gas. Some well-known materials for H<sub>2</sub>S gas sensing are SnO<sub>2</sub>-ZnO-CuO [16], SnO<sub>2</sub>-Pd [17], SnO<sub>2</sub>-Al<sub>2</sub>O<sub>3</sub> [18], SnO<sub>2</sub>-CuO [19]-[24], SnO<sub>2</sub>-CuO-SnO<sub>2</sub> [25], and ZnSb<sub>2</sub>O<sub>6</sub> [26] Researchers have developed various types of sensors by adding different additives<sup>1,27-29</sup> into semiconducting BaTiO<sub>3</sub>. The sensing materials modified by incorporating different additives, either by doping or dipping technique. The sensing performance of pure and modified BaTiO<sub>3</sub> films was studied in terms of the change in conductance in the presence and absence of gases.

## II. EXPERIMENTAL

### A. Preparation of BaTiO<sub>3</sub> Powder

Powders of Ba(OH)<sub>2</sub>·8H<sub>2</sub>O and TiO<sub>2</sub> of analytical reagent grade were ball milled to mix thoroughly at the same molar concentrations. The mixture was sintered at 1000°C for 6h to obtain BaTiO<sub>3</sub><sup>30,31</sup>. The fine-grain powder of BaTiO<sub>3</sub> was obtained by milling in a planetary ball mill for 2h. The sub micron size powder was then used to formulate the paste for printing of thick films.

**B. Preparation of BaTiO<sub>3</sub> Thick Films**

The thixotropic paste was formulated by mixing the fine powder of BaTiO<sub>3</sub> with a solution of ethyl cellulose (a temporary binder) in a mixture of organic solvents such as butyl cellulose, butyl carbitol acetate and terpineol, etc. The ratio of the inorganic to organic part was kept at 75:25 in formulating the paste. This paste was screen printed [32][33] on a glass substrate in a desired pattern. The films were fired at 550°C for 30min. Silver contacts were made for electrical measurements.

**C. Preparation of Cr<sub>2</sub>O<sub>3</sub>-doped BaTiO<sub>3</sub> Thick Films**

Different wt% of CrO<sub>3</sub> was added in BaTiO<sub>3</sub>, base material, followed by sintering at 550°C for 30min. CrO<sub>3</sub> is not thermally stable above its melting temperature (197°C). At higher temperature, it loses oxygen to give stable Cr<sub>2</sub>O<sub>3</sub>. In this way, the Cr<sub>2</sub>O<sub>3</sub>-doped BaTiO<sub>3</sub> powder was obtained. The thick films of such powder were prepared by screen-printing technique.

**D. Measurements**

By using the Taylor-Hobson (Talystep, UK) system, the thickness of the thick films was measured. The thicknesses of the films were observed in the range from 65 to 70 nm. By maintaining the proper rheology and thixotropy of the paste, the reproducibility in thickness of the films was possible.

**E. Characterization Results**

1) **Microstructural Analysis:** Figure 1(a) depicts a SEM image of an unmodified BaTiO<sub>3</sub> thick film fired at 550°C. The film consists of voids and a wide range of particles with particle sizes ranging from 200 to 1330 nm distributed non-uniformly. Figures 4.2(b-d) depict SEM images of Cr<sub>2</sub>O<sub>3</sub>-doped BaTiO<sub>3</sub> thick films fired at 550°C with 0.56, 5.27 and 6.07wt% of Cr, respectively. The agglomeration of particles increases as Cr<sub>2</sub>O<sub>3</sub> wt% increases. The change in doping concentration changes the particle sizes. The particle sizes ranging from 0.3 to 1.0µm (Fig.1(b)), 0.5 to 1.0µm (Fig. 1 (c)), and 0.66 to 2µm (Fig. 1(d)) were observed.

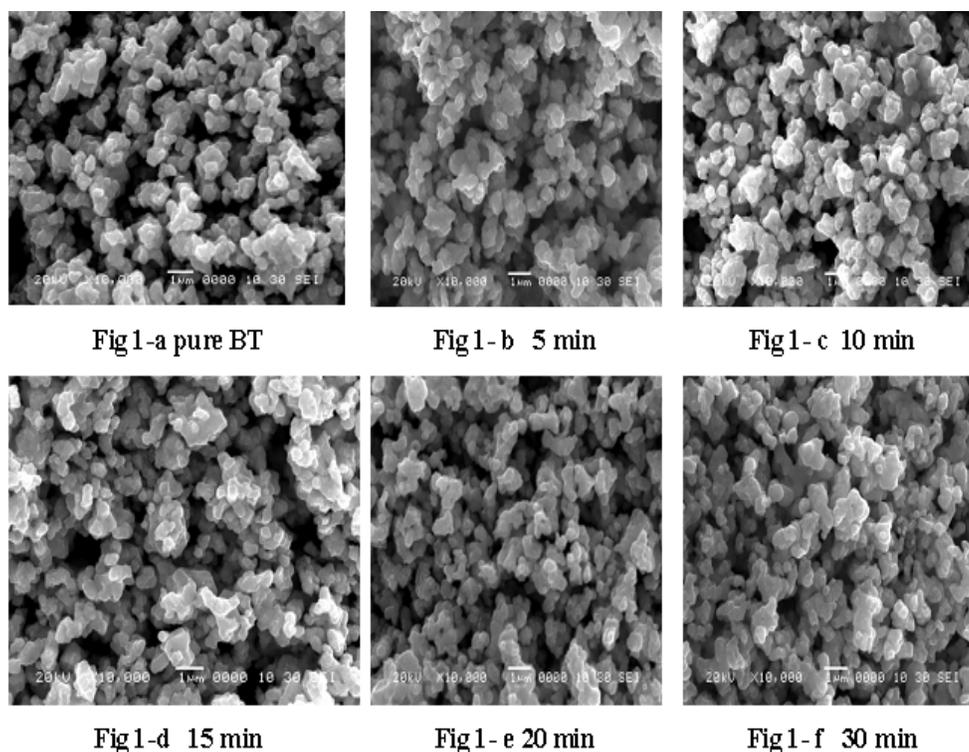


Figure 1: SEM images of (a) unmodified BaTiO<sub>3</sub> film and Cr<sub>2</sub>O<sub>3</sub>-doped BaTiO<sub>3</sub> films CrBT1, CrBT2, CrBT3, CrBT 4 and CrBT5

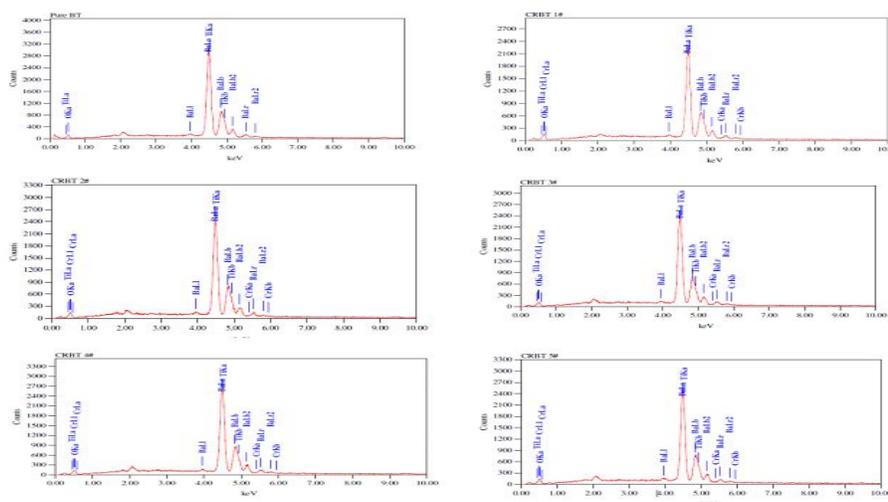


Fig. 2 (a-f): EDX spectra of pure BT and Cr surface modified BT thick films

F. Elemental Analysis

Using an energy dispersive spectrometer and atomic percentage (mass %) of Ba, O and Cr are represented in Table 3.3 the quantitative elemental composition of the pure and Cr modified BT films was analyzed,. All samples were oxygen deficient. The films dipped in Cr were observed to be most oxygen deficient than the pure BT film. It is clear from Table 1 that the mass % of Cr increases and mass % of oxygen goes on decreases with the dipping time.

Table 1: Quantitative elemental composition of pure BT and surface modified CrBT thick films

Element	Pure BT	CrBT1	CrBT 2	CrBT3	CrBT4	CrBT5
	mass %	mass %	mass %	mass %	mass %	mass %
O	16.46	15.96	15.36	15.95	15.84	16.39
Ti	11.06	10.93	9.92	10.96	10.74	11.91
Ba	72.48	72.64	74.58	72.69	73.09	71.49
Cr	-	0.47	0.14	0.40	0.33	0.21
Total	100	100	100	100	100	100

G. Electrical Conductivity of Cr<sub>2</sub>O<sub>3</sub>-doped BaTiO<sub>3</sub> Films

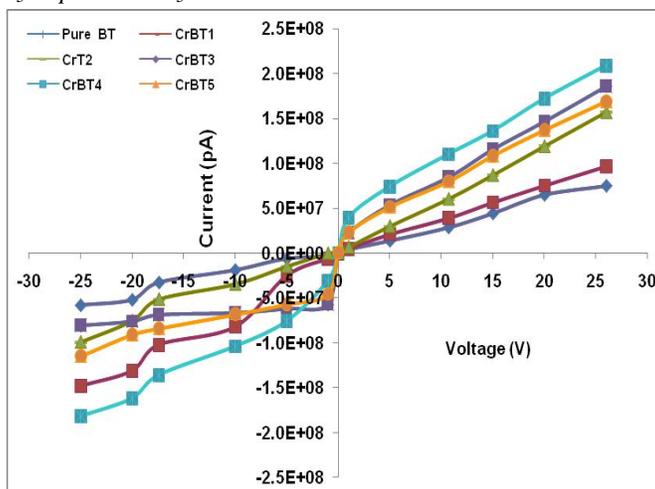


Fig. 3 I-V characteristic for pure BT, CrBT1, CrBT2, CrBT3, CrBT4 and CrBT5

Fig. 3 shows the I-V characteristics of samples pure BT, CrBT1, CrBT2, CrBT3, CrBT4 and CrBT5. It is observed that they are nearly symmetrical in nature indicating ohmic nature of contacts. Due to semiconducting nature of the films, the non-linear I-V characteristics are observed.

H. Electrical conductivity

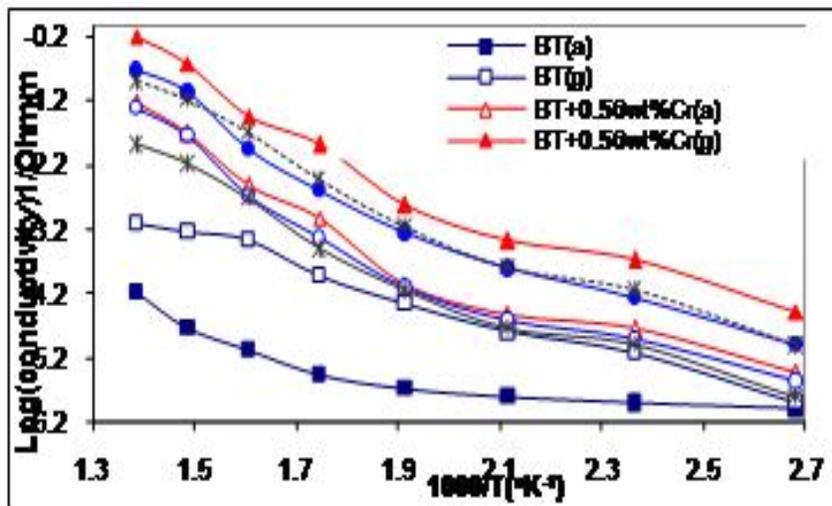


Figure 4 : Variation of electrical conductivity with temperature.

Figure 4 represents the variation of conductivity with temperature for the pure BaTiO<sub>3</sub> and Cr-BaTiO<sub>3</sub> (BT) films. The legends suffixed with ‘a’ are the graphs for the conductivities of the films in the air ambient, while legends suffixed ‘g’ are the graphs for conductivities of the films in the NH<sub>3</sub> gas ambient. It is clear from the graphs that the conductivity is varying approximately linearly with temperature for all films. The conductivity of Cr-BaTiO<sub>3</sub> films was observed to be increased.

Fig. 5 represents the variation of conductivity with temperature BT thick film. From the graphs it is clear that the conductivity is varying with temperature. The resistance decreases dramatically in the 450–350 °C region due to semiconducting nature of sample., The change in resistance is very small in the 325- 200 °C region. As the conductance of the Cr-BT hardly changes from 325°C to 200 °C has good thermal stability when its operating temperature is in this range.

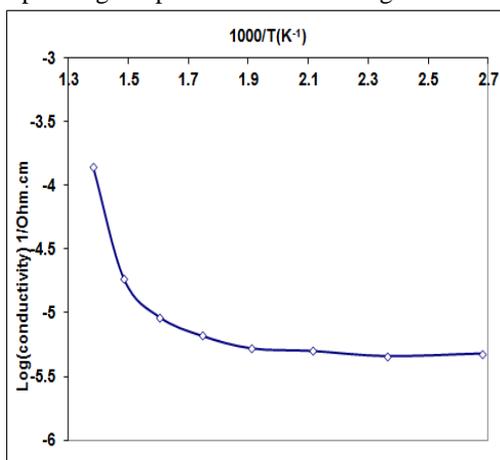


Fig. 5: Variation of conductivity with temperature

I. Temperature dependence of sensitivity of pure and modified BT thick films to H<sub>2</sub>S

In a gas test chamber the sensor was placed, exposed to gases. By the measurements of sensitivity S, the properties of the investigated sensor were determined. This parameter was defined as the ratio of sensor electrical conductance in air (I<sub>a</sub>) to that containing detected gas (I<sub>g</sub>) [23].

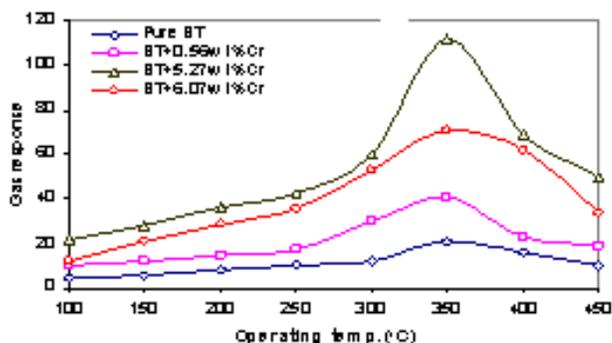


Fig. 6: Variation of sensitivity of pure and Cr modified BT thick films with operating temperature.

J. Selectivity

Figure 7 shows the bar diagram of the selectivity of pure and Cr<sub>2</sub>O<sub>3</sub>-doped BaTiO<sub>3</sub> films to various gases at optimum operating temperature. The table attached to bar diagram indicates the gas response values to various gases. The pure BaTiO<sub>3</sub> film showed highest H<sub>2</sub>S gas response while Cr<sub>2</sub>O<sub>3</sub>-doped BaTiO<sub>3</sub> films showed highest response to NH<sub>3</sub> gas.

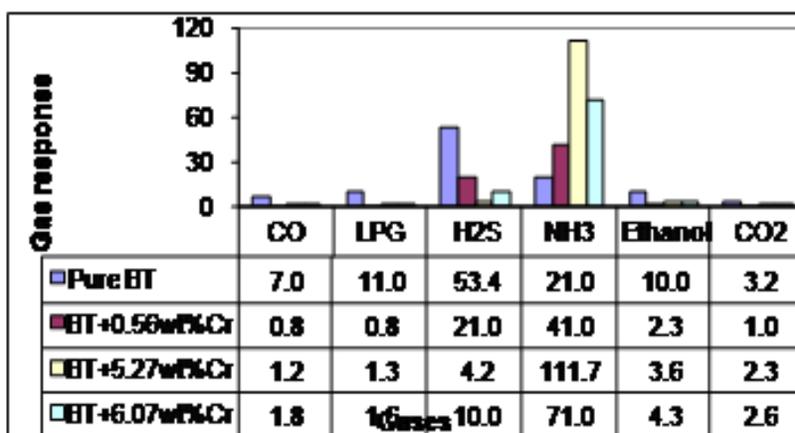


Fig.7 Selectivity of Cr<sub>2</sub>O<sub>3</sub>-doped BaTiO<sub>3</sub> films to various gases.

Table 2 shows the selectivity coefficients of pure and Cr<sub>2</sub>O<sub>3</sub>-doped films to NH<sub>3</sub> gas against the other gases. The film with 5.27 wt% of Cr was more selective to NH<sub>3</sub> gas against the other gases as compared to other films.

Table 2: Selectivity coefficient.

Sample	K <sub>CO</sub>	K <sub>LPG</sub>	K <sub>H<sub>2</sub>S</sub>	E <sub>Ethanol</sub>	K <sub>CO<sub>2</sub></sub>
BT+0.56wt%Cr	51.25	51.25	1.95	17.82	41
BT+5.27wt%Cr	93.05	85.9	26.79	31.01	48.55
BT+6.07wt%Cr	39.44	44.37	7.1	16.51	27.30

K. Response and recovery time of Cr<sub>2</sub>O<sub>3</sub>-doped BaTiO<sub>3</sub> sensor

The transient response of Cr<sub>2</sub>O<sub>3</sub>-doped (5.27 wt%) BaTiO<sub>3</sub> film to NH<sub>3</sub> gas is depicted in Fig. 8. The gas response of this film was found to be largest at 350°C. The 90% response and recovery levels were attained within 3 and 20s, respectively for this sample. The very short response and recovery time are the important features of this Cr<sub>2</sub>O<sub>3</sub>-doped BaTiO<sub>3</sub> film to NH<sub>3</sub> gas.

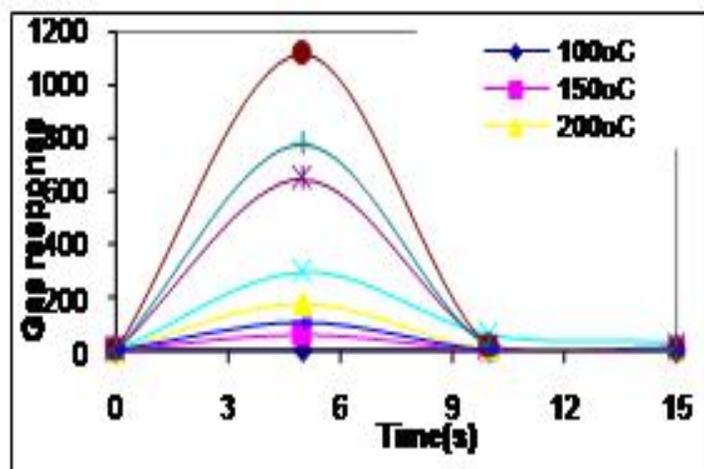


Fig. 8. The gas response of  $\text{Cr}_2\text{O}_3$ -doped (5.27wt%)  $\text{BaTiO}_3$

Fig.9 shows the variations in  $\text{H}_2\text{S}$  gas response with speed of response time in seconds for the CrBT (20min) film operated during  $100^\circ\text{C}$  through  $450^\circ\text{C}$  and fired at  $550^\circ\text{C}$ . The very short response and recovery time are the important features of the CrBT. The 90% response and recovery levels were attained within 3 and 9s, respectively.

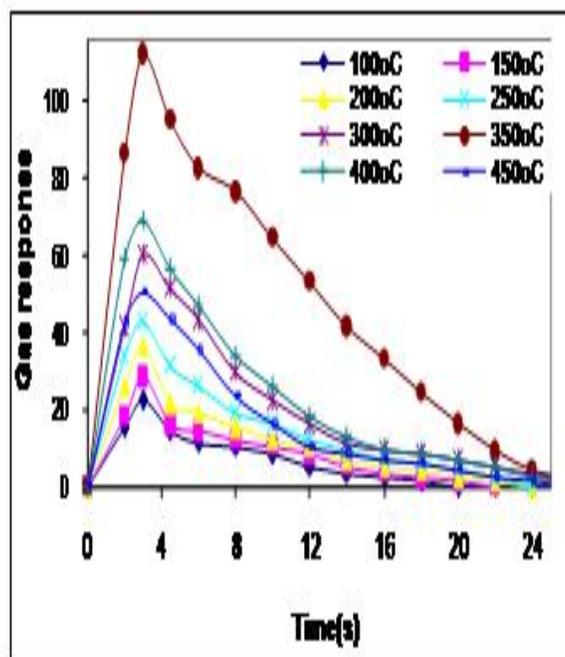


Fig. 9 Transient response of  $\text{Cr}_2\text{O}_3$ -doped (5.27wt%)  $\text{BaTiO}_3$  to  $\text{NH}_3$  gas

#### L. Gas response with operating temperature

Fig. 10 shows variations in response to  $\text{H}_2\text{S}$  gas (100ppm) with operating temperature of the unmodified (pure) and modified (chrominated)  $\text{BaTiO}_3$  films, fired at  $550^\circ\text{C}$ . The response values of unmodified and surface Cr-BT films were determined at various operating temperatures ranging from  $100$  to  $450^\circ\text{C}$  to  $\text{H}_2\text{S}$  gas. The response goes on increasing with the operating temperature, attains its maximum (at  $350^\circ\text{C}$ ) and then decreases with a further increase in operating temperature. It is observed from that the optimum operating temperature is  $350^\circ\text{C}$ .

The  $\text{H}_2\text{S}$  response of unmodified  $\text{BaTiO}_3$  fired at  $550^\circ\text{C}$  was 53 at  $350^\circ\text{C}$ , and of surface chrominated for 20min  $\text{BaTiO}_3$  was 1119 at the same operating temperature. Hence, the surface chromination of  $\text{BaTiO}_3$  was observed more effective in  $\text{H}_2\text{S}$  gas sensing than the unmodified  $\text{BaTiO}_3$ .

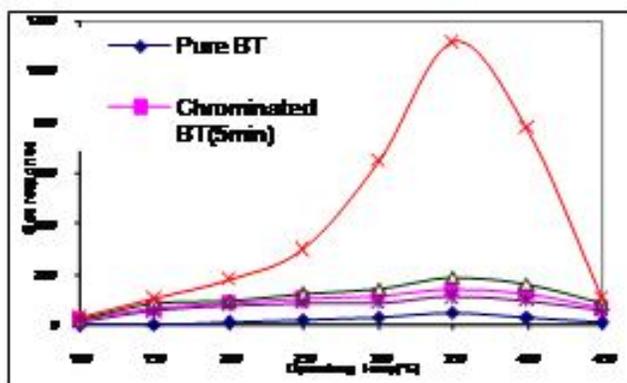


Fig. 10 Variations in H<sub>2</sub>S gas (100ppm) response with operating temperature.

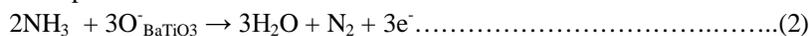
### III. DISCUSSION

#### A. Cr<sub>2</sub>O<sub>3</sub>-doped BaTiO<sub>3</sub> as a NH<sub>3</sub> gas sensor

Atmospheric oxygen molecules are adsorbed on the surface of Cr<sub>2</sub>O<sub>3</sub>-doped BaTiO<sub>3</sub> semiconductor oxide in the forms of O<sup>-</sup> and O<sub>2</sub><sup>-</sup> thereby decreasing the electronic conduction. Atmospheric oxygen molecules take electrons from the conduction band of Cr<sub>2</sub>O<sub>3</sub>-doped BaTiO<sub>3</sub> to be adsorbed as O<sup>-</sup><sub>BaTiO<sub>3</sub></sub>. The reaction is as follows:



The Cr<sub>2</sub>O<sub>3</sub>-doped BaTiO<sub>3</sub> is more oxygen deficient as compared to pure BaTiO<sub>3</sub>. The excess Ba ions (due to oxygen vacancies) act as donors [42]. When reducing gas molecules like NH<sub>3</sub> react with negatively charged oxygen adsorbates, the trapped electrons are given back to conduction band of Cr<sub>2</sub>O<sub>3</sub>-doped BaTiO<sub>3</sub>. The energy released during decomposition of adsorbed ammonia molecules would be sufficient for electrons to jump up into conduction band of Cr<sub>2</sub>O<sub>3</sub>-doped BaTiO<sub>3</sub>, causing an increase in the conductivity of sensor. The possible reaction is:



To proceed this reaction to the right hand side, some amount of activation energy has to be provided thermally. An increase in operating temperature surely increases the thermal energy so as to stimulate the oxidation of NH<sub>3</sub> (Eq. (2)). The reducing gas (NH<sub>3</sub>) donates electrons to Cr<sub>2</sub>O<sub>3</sub>-doped BaTiO<sub>3</sub>. Therefore, the resistance decreases, or the conductance increases. That is why the gas response increases with operating temperature. The point at which the gas response reaches maximum is the actual thermal energy needed for the reaction to proceed. However, the response decreases at higher operating temperatures, as the oxygen adsorbates are desorbed from the surface of sensor [43]. Also, at high temperatures the carrier concentration increases due to intrinsic thermal excitation and the Debye length decreases. This is the reasons for the decreased gas response at high temperatures [44].

When the optimum amount of Cr (5.27wt%) is incorporated into the BaTiO<sub>3</sub> material, the Cr<sub>2</sub>O<sub>3</sub> species would be uniformly distributed. Because of this, not only the initial resistance of the film is high but this amount would also be sufficient to promote the catalytic reaction effectively and the overall change in the resistance on exposure of ammonia gas leading to high sensitivity. When the amount of Cr<sub>2</sub>O<sub>3</sub> on the surface of base material, BaTiO<sub>3</sub>, is less than the optimum, the dispersion may be poor and the sensitivity of the film is decreased since this amount may not be sufficient to promote the reaction effectively. On the other hand, as the amount of Cr<sub>2</sub>O<sub>3</sub> on BaTiO<sub>3</sub> surface is more than the optimum, an additive Cr<sub>2</sub>O<sub>3</sub> would be distributed more densely. As a result, base material BaTiO<sub>3</sub> would be masked and the overall change in the resistance on the exposure of gas would be smaller leading to lower response to ammonia gas.

#### B. Cr-BT as a H<sub>2</sub>S gas sensor

Above its melting temperature (197°C) the chromium oxide (CrO<sub>3</sub>) on the surface of BaTiO<sub>3</sub> film is not thermally stable, losing oxygen to give Cr<sub>2</sub>O<sub>3</sub> after series of intermediate stages [45]. In this investigation, it is usual procedure, to test the sensors by heating them at operating temperatures ranging from 50°C to 450°C. The first time heating of a sensor above 200°C would convert CrO<sub>3</sub> into Cr<sub>2</sub>O<sub>3</sub>. Hence the surface chrominated films can be looked upon as the small particles of chromium oxide (Cr<sub>2</sub>O<sub>3</sub>) distributed along the grain boundaries of BaTiO<sub>3</sub> leading to very high resistance.



At elevated temperatures, when oxygen is adsorbed on the chromium zones of strong localization the potential between the BaTiO<sub>3</sub> grains may be raised further and as a result the total resistance increases in comparison with the sample without chromium. It is known that abstraction of electrons from bulk BaTiO<sub>3</sub> by the adsorbed oxygen results in the formation of surface states. The amount of oxygen adsorbed on the surface of Cr-BT films would be larger since chromium oxide would form misfit regions between the grains of BaTiO<sub>3</sub> and would act as an efficient catalyst for oxygenation.

On exposure of reducing gas such as H<sub>2</sub>S on BaTiO<sub>3</sub> based films, it would be oxidized and the potential barrier would be decreased as a result of oxidative conversion of the H<sub>2</sub>S gas and desorption of oxygen. The reaction of H<sub>2</sub>S with the adsorbed oxygen ions can be represented as:



In addition to this the conversion of chromium oxide into well conducting sulphides decreases the resistance on exposure of H<sub>2</sub>S gas. The amount and its distribution on the surface are also the important factors influencing the gas response. Due to desorption of adsorbed oxygen ions and release of electrons back to the film, and the resistance of the film would change abruptly leading to high response to H<sub>2</sub>S.

The H<sub>2</sub>S gas is reducing in nature. It reduces Cr<sub>2</sub>O<sub>3</sub> into Cr<sub>2</sub>S<sub>3</sub> or CrS, which are metallic in nature and are more conducting than Cr<sub>2</sub>O<sub>3</sub> [46]. Upon exposure to H<sub>2</sub>S gas of the Cr-BT, it would reduce the chromium oxide (Cr<sub>2</sub>O<sub>3</sub> or CrO). This can be represented as:



The film resistance would decrease suddenly and largely due to the reduction of chromium oxide into sulphides,. This can be attributed to the high sensitivity of the chrominated films.

Upon subsequent exposure of sensor to ambient air at elevated temperatures, sulphides got oxidized and could be recovered back to oxides as:



On the surface of the BaTiO<sub>3</sub> film, when the optimum amount of chromium oxide is dispersed, chromium species would distribute uniformly throughout the surface. Due to this, not only the initial resistance of the film was high, but this amount would also be sufficient to promote the catalytic reaction effectively and the overall change in resistance upon exposure to the test gas gets larger leading to high response to the gas. When the amount of chromium oxide on the surface of the film was less than the optimum, the surface dispersion would be poor and the amount might not be sufficient to promote the reaction more effectively, leading to lower gas response. Observations from thermal analysis indicate that the surface Cr-BT was more stable than pure BaTiO<sub>3</sub>. Hence, reproducibility of chrominated samples is expected to be better than pure BaTiO<sub>3</sub>. The adsorption of oxygen on the Cr-BT would be more effective as compared to pure BaTiO<sub>3</sub> leading to higher gas response.

The semiconducting nature may be attributed to oxygen deficiencies in BaTiO<sub>3</sub>. The nonlinearity of the electrical conductivity-temperature profiles of the samples reveals the semiconducting nature of pure and Cr-BT. Cr of BaTiO<sub>3</sub> has enhanced the electrical conductivity. This may be due to the bridging of intergranular gaps between BaTiO<sub>3</sub> particles by small particles of Cr<sub>2</sub>O<sub>3</sub> segregated around the grain boundaries of BaTiO<sub>3</sub>.

A large number of oxygen ions would be adsorbed on the misfit regions of chromium in ambient air. Fast recovery and response to H<sub>2</sub>S gas may be due to faster adsorption-desorption reactions on the surface of the Cr films. The larger the misfits on the surface, the larger would be the number of oxygen ions adsorbed on the surface leading to high resistance. . The larger the oxygen deficiency, the faster would be the adsorptions of oxygen ions and in turn the faster the recovery of the sensor. The larger the number of oxygen ions adsorbed on the surface, the faster would be the oxidation of the exposed gas and the response time. BaTiO<sub>3</sub> was observed to be highly oxygen deficient

#### IV. SUMMARY AND CONCLUSIONS

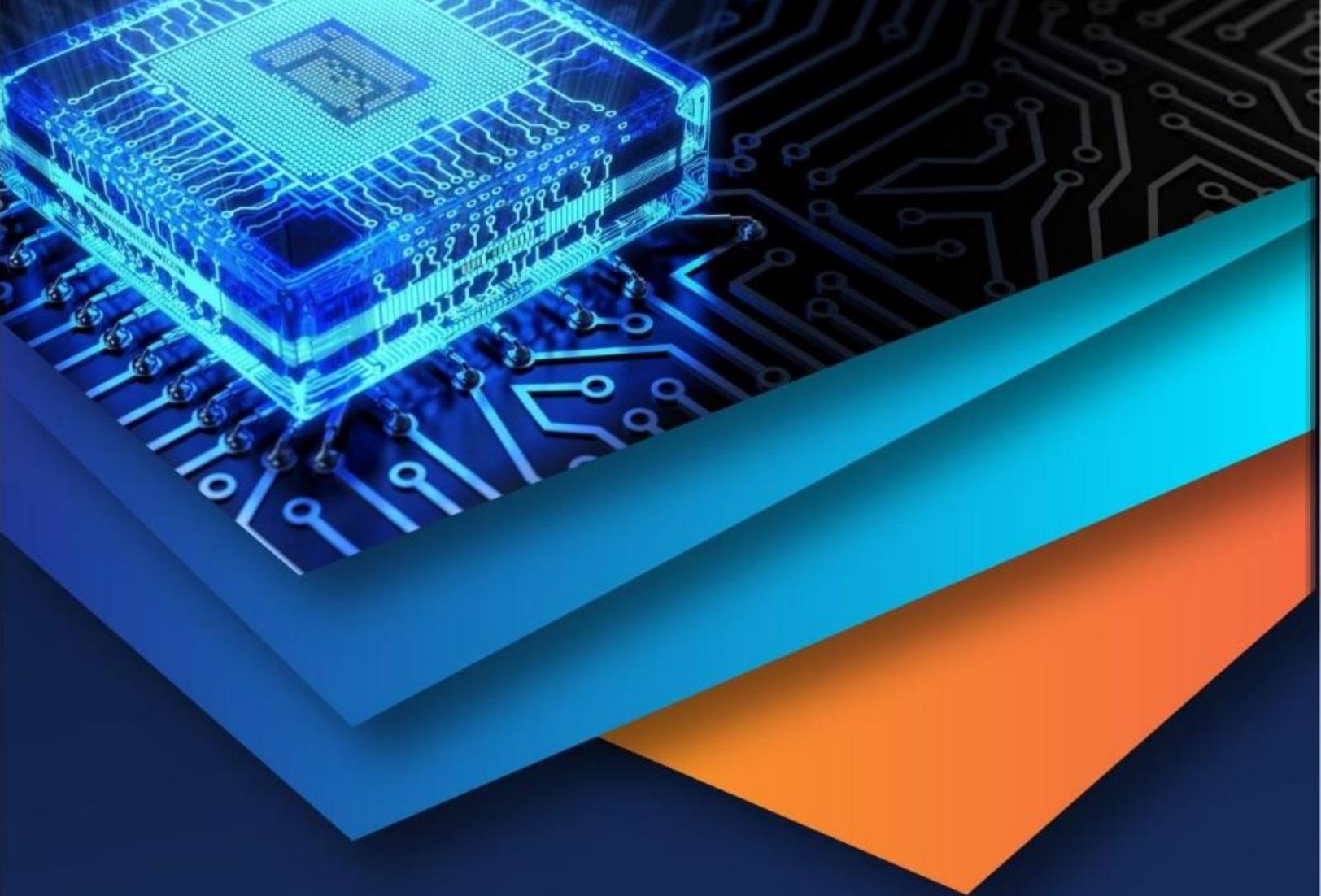
From the experimental results following statements can be made.

- A. The thick films of pure BT were sensitive to H<sub>2</sub>S gas.
- B. The CrBT was most sensitive and selective to NH<sub>3</sub> gas.

- C. The CrBT was observed to be semiconducting in nature and showed a negative temperature coefficient of resistance.
- D. The resistance of the CrBT films in ambient air was observed to be very high.
- E. The resistance of the CrBT films was observed to decrease suddenly upon exposure to H<sub>2</sub>S gas at optimum operating temperature.
- F. Chromium oxide formed misfits on the surface region. The larger the misfits on the surface, the larger would be the number of oxygen ions adsorbed on the surface, leading to high resistance.
- G. The surface chromination facilitated adsorption of a large number of oxygen ions on the surface, which could immediately oxidize the exposed H<sub>2</sub>S gas, leading to faster response time of the sensor.
- H. The fast recovery of the sensor could be attributed to the larger oxygen deficiency in BT. The larger oxygen deficiency would enable BT to adsorb more oxygen ions, helping the sensor to recover fastly.
- I. Surface CrBT was observed to be more sensitive to H<sub>2</sub>S gas than unmodified BT..
- J. The CrBT was observed to be highly selective to H<sub>2</sub>S gas.

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